WHAT IS CLAIMED IS:

- 1 1. A light-emitting apparatus comprising:
- 2 a transparent base made of an inorganic material;
- a first and a second bonding pad formed on the base;
- 4 a Gan semiconductor light-emitting device having a first
- 5 and a second electrode on one side thereof;
- a first and a second wire which connect/said first bonding
- 7 pad to said first electrode and said second bonding pad to said second
- 8 electrode, respectively;

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- a transparent adhesive layer which fixes the transparent substrate of said semiconductor light-emitting device to a first surface of said base;
- a transparent resin which encapsulates said base, said light-emitting device, said first and second wires, said first and second lead frames, and said adhesive layer.
- a first and a second/lead frame to which said transparent base is fixed so that the substrate of said semiconductor light-emitting device may face the dominant light emitting direction of said light-emitting apparatus, and said first and second bonding pads being electrically connected to said first and second lead frames,
- 20 respectively.
 - A light-emitting apparatus according to claim 1, wherein
 - 2 said first bonding pad and said second bonding pad are provided on
 - 3 said first surface of said base, said first lead frame has a first

- mount facing said dominant light emitting direction, said second legal 4
- frame has a second mount facing said dominant light emitting 5
- direction, said first bonding pad is fixed onto said first mount with 6
- an electrical connection, and said second bonding pad is fixed onto
- said second mount with an electrical connection. 8
- A light-emitting apparatus according to claim 1, wherein 1 3.
- each of said first and second electrodes is a /light-reflecting and 2
- electrically conducting metal layer.

- 1 A light-emitting apparatus according to claim 1, wherein
- said base is made of a material selected from the group consisting 2
- of a SiO,, sapphire and borosilicate glass.
- A light-emitting apparatus according to claim 2, wherein 5.
 - said base is made of a material selected from the group consisting 2
 - of a SiO2, sapphire and borosilicate glass.
 - A light-emitting apparatus according to claim 3, wherein 1
 - said base is made of a material selected from the group consisting
 - of a SiO2, sapphire and borosilicate glass.
 - A light-emitting apparatus according to claim 2, wherein 1
 - said AaN semiconductor light-emitting device is fixed on said first
 - surface of said base between said first and second bonding pads.

A light-emitting apparatus according to claim 7, wherein 8. 1

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- said base is rectangular in its plane view. 2
- A light-emitting apparatus according to claim 7, wherein
- said first and second bonding pads are formed substantially in
- parallel with the long side of said first surface,
- A light-emitting apparatus according to any one of claims 10. 1
- 1 to 9, wherein said base has dispersed/therein a fluorescent
- 3 material.

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- M A light-emitting apparatus according to any one of claims **II** 1 11.
- 1 to 9, wherein said base is defined by a plurality of layers, and
 - at least one of said layers/contains a fluorescent material. 3
- A light-emitting apparatus according to claim 10, wherein 12.
 - said base is defined by a plurality of layers, and at least one of
 - said layers contains a fluorescent material.
 - 13. A light-emitting apparatus according to claim 1, wherein 1
 - the first and second bonding pads are formed on a diagonal line of
 - the tipst surface of the base.
 - A semiconductor light-emitting apparatus of flip chip 14. bonding type, comprising:

a transparent base made of an inorganic material, which has 3

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- on one side thereof a first bonding pad and a second bonding pad to
- be connected to a pair of lead frames with a space between the first 5
- and the second bonding pads where a semiconductor light-emitting б
- element is to be fixed. 7

A semiconductor light-emitting apparatus of flip chip 15 bonding type as claimed in claim 14, wherein the inorganic material is selected from the group consisting of a SiO2, sapphire and borosilicate glass.

- A semiconductor light-emitting apparatus of flip chip 16.
- bonding type as claimed in claim 14, said transparent base is
- rectangular in its plane view.
- A semiconductor light-emitting apparatus of flip chip 17. 1
- bonding type as claimed in claim 14, wherein the inorganic material
- has a fluorescent material dispersed therein.
- A semiconductor light-emitting apparatus of flip chip 18. 1
- bonding type as claimed in claim 14, said transparent base a plurality
- of layers, and at least one of the layer's contains a fluorescent
- material.

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A pair of lead frames for use in a light-emitting apparatus of flip chip bonding type comprising:

a transparent base having on a first surface thereof a first and a second bonding pad and

a GaN semiconductor light-emitting device fixed on the first surface thereof,

wherein a first lead frame has a first mount which faces the dominant light emitting direction of the light-emitting apparatus and on which the first bonding pad is to be fixed, and a second lead frame has a second mount which faces the dominant light emitting direction and on which the second bonding pad is to be fixed.

A pair of lead frames according to claim 19, wherein the 20. first lead trame has a first projection on which diffused light from the light-emitting device is to be reflected toward the dominant light-emitting direction, and the second lead frame has a second projection on which diffused light from the light-emitting device is to be reflected toward the dominant Light-emitting direction.